

Structural Properties of SrTiO₃/GaAs Hetero-interfaces

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The SrTiO₃/GaAs hetero-interface is being studied due to the interest of using it in metal-oxide-semiconductor field-effect transistors, where the GaAs substrate would act as the semi-insulating base material and the SrTiO₃ would act as the barrier oxide layer between the GaAs and the gate material. Previously, SrTiO₃ ultra-thin film deposited on As-terminated GaAs substrate have been studied experimentally [1-3]. SrO termination for SrTiO₃ is found to be more stable than TiO₂ at the interface. However, whether Ga- or As-terminated GaAs is more stable at the interface remains unclear. In this work, GaAs thin film layers are grown on SrTiO₃ instead of using GaAs as substrate. The SrTiO₃/GaAs hetero-interface is characterized using atomic-resolution Z-contrast imaging and energy dispersive spectroscopy (EDS) mapping, along with density functional theory (DFT) calculations.

The sample used in this work is grown using molecular beam epitaxy method. A 10 nm Sr-terminated SrTiO₃ thin film is grown on Si (001) substrate with a 4° miscut in the [110] direction and a 2 nm thick SiO₂ buffer layer. Simultaneous Ga and As₂ are exposed to the SrTiO₃ surface to form a 1 μm thick epitaxial GaAs layer. The Z-contrast images (Figure 1a and b) are obtained using the aberration-corrected JEOL JEM-ARM200CF scanning transmission electron microscopy (STEM) at 200kV. Figure 1a shows the layered structure of the sample. Step structures are observed at SrTiO₃ (001) surface. Figure 1b shows the atomic structure at the SrTiO₃/GaAs interface, and can be separated into two areas (Area I and Area II) according to the two steps at SrTiO₃ surface. In Area I, we find that the SrTiO₃[100] direction is parallel to GaAs[110], and the heterointerface appears sharp with the GaAs dumbbells in perfect registry with the O atoms in the SrO terminating layer. Due to the step of one unit cell of SrTiO₃ (3.90 Å), 3/4 unit cell of GaAs (4.24 Å) is missing at the interface in Area II. Therefore, GaAs columns in Area II are not perfectly aligned with SrTiO₃ columns due to the lattice mismatch as shown in the image. The sequence of the GaAs dumbbell is determined using the intensity line scan in the Z-contrast image along with atomic-resolution EDS mapping as shown in Figure 2a and b. The intensity profile is consistent with the EDS mapping that the sequence of the GaAs dumbbell in the Z-contrast image is Ga-As, which means, at the interface, the GaAs film is terminated with Ga in Area I while terminated with As in Area II as the structural model insets shown in Figure 1b. According to our DFT calculations [4], the SrO/Ga interface with Ga-O bonding is energetically most favorable among all the proposed configurations, which is in good agreement with the Z-contrast image in Area I. The interfacial structure becomes more interesting when SrTiO₃ steps are introduced as shown in Area II. A more detailed study of the step structures using electron energy-loss spectroscopy will be presented where the fine structure of interfacial atoms will be examined. [5]

References:

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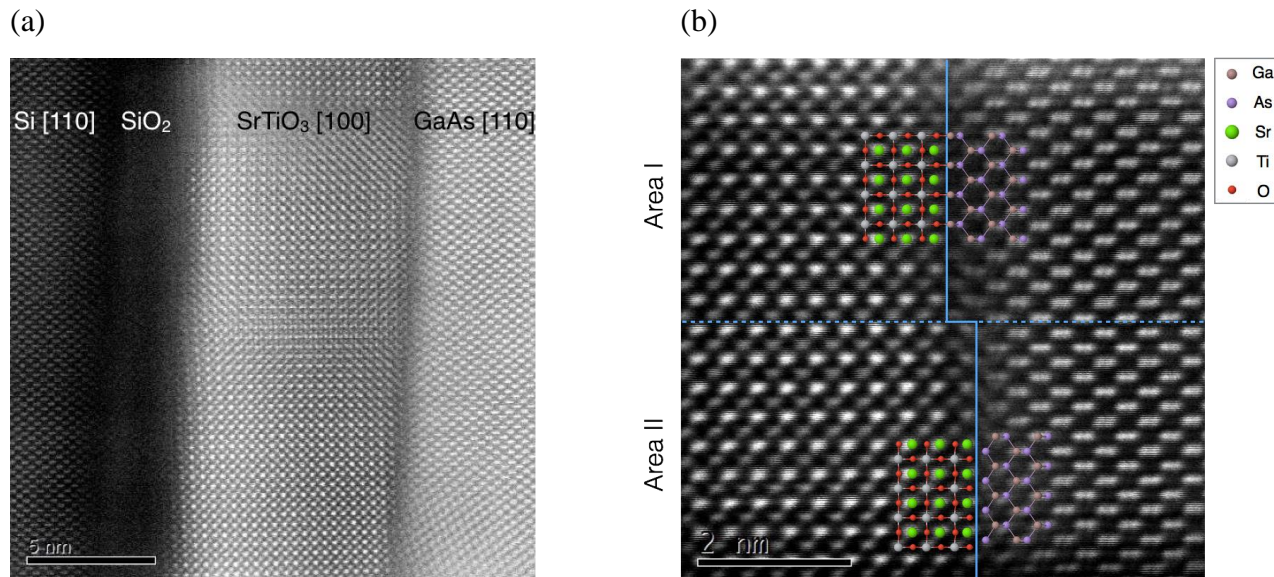


Figure 1 (a) Cross-sectional Z-contrast STEM image of the layered structure of the sample used in this work. (b) (Color online) Atomic-resolution Z-contrast STEM image of the SrTiO₃/GaAs hetero-interface. The proposed structural models of the atomic arrangement at the interface are shown as insets. The step structure of the interface is marked by blue solid line. Area I and II are separated by blue dashed line. Radial Wiener Filter within Gatan Digital Micrograph is used to reduce noise in the Z-contrast images.

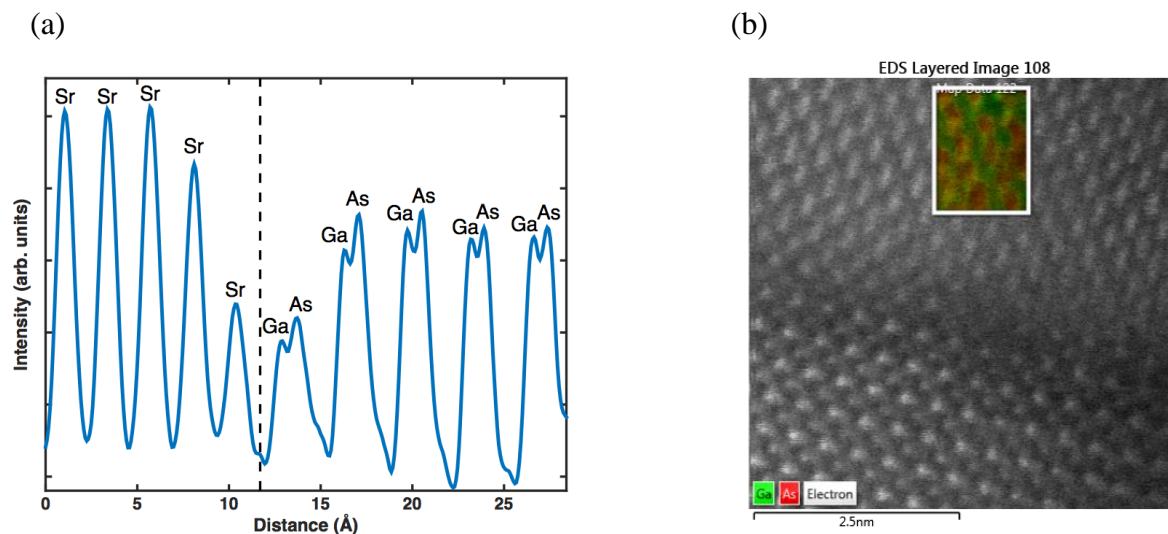


Figure 2 (a) Intensity scan of the Sr/GaAs atomic column in the Z-contrast image in Figure 1b. The dashed line denotes the interface. The intensity is averaged for the eight Sr/GaAs atomic columns in Area I and is smoothed using Gaussian function. Since the intensity is proportional to Z^2 , where Z is the atomic number, the intensity of Ga atoms is slightly lower than that of As atoms. (b) (Color online) Atomic-resolution EDS mapping of GaAs near the interface. Ga (As) atoms locate at the lower (upper) positions in the dumbbells.